

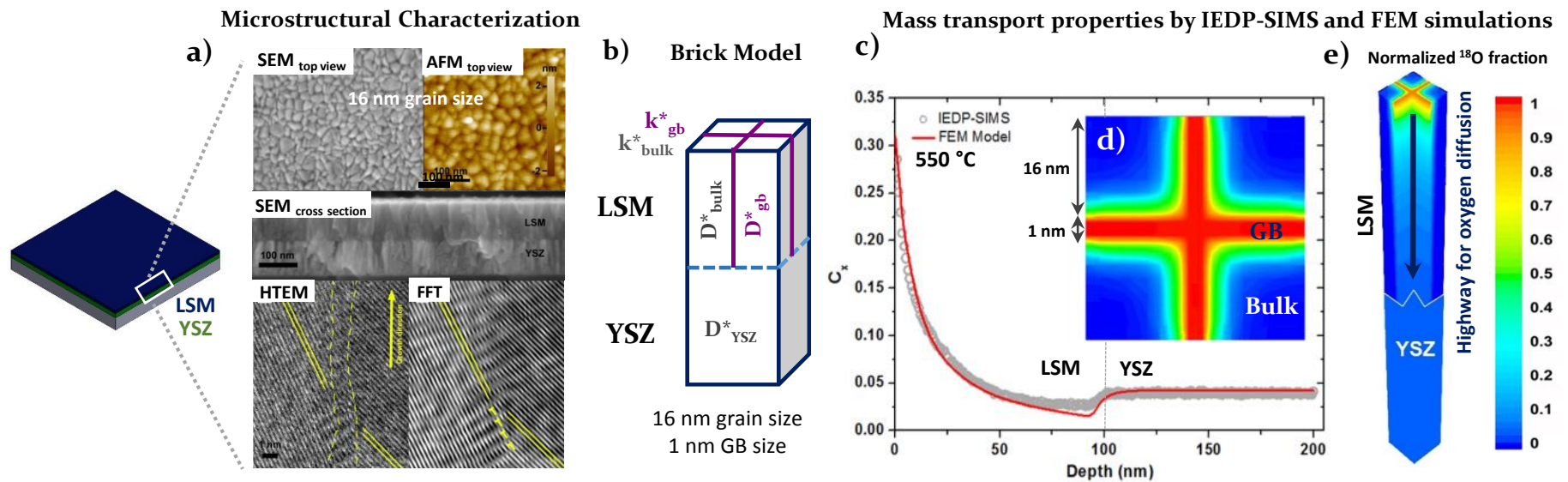
# Evaluation of the Mass Transport Properties of $\text{La}_{0.8}\text{Sr}_{0.2}\text{MnO}_{3\pm\delta}$ nanostructures by Finite Element Method (FEM) Simulations

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## ■ NANOENGINEERING THIN FILMS: nanostructures with a high density of grain boundaries (GBs)

$\text{La}_{0.8}\text{Sr}_{0.2}\text{MnO}_{3\pm\delta}$  (LSM) dense film deposited by PLD on polycrystalline YSZ films



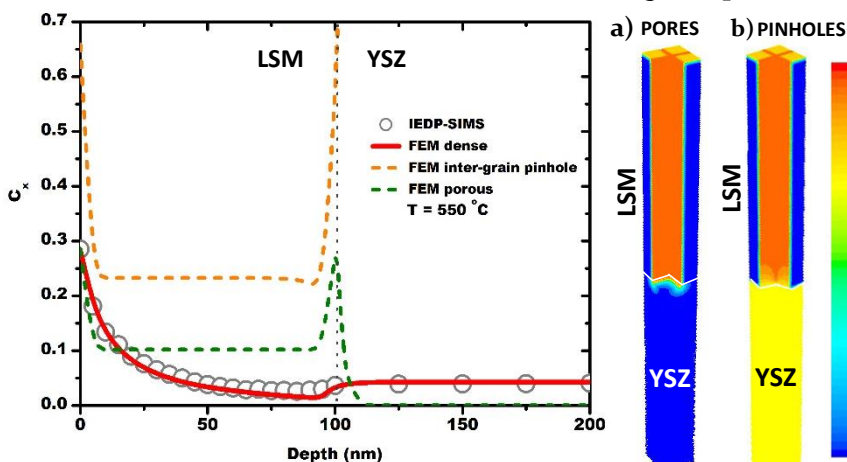
(a) The high density of vertically aligned GBs leads to a high concentration of strain-induced defects.

(b) Model proposed for the FEM simulations.

(c) Normalized  $^{18}\text{O}$  isotopic fraction and fitted solution by FEM at 550°C. (d) Top view and (e) cross section of the isotopic fraction map by FEM.

## ■ EFFECT OF DEFECTS in diffusion profiles

Short circuit paths down nanopores or inter-grain pinholes



Differences in the isotope fraction profiles at 550°C due to short circuit paths: (a) porosity in the place of GB and (b) 1x1nm<sup>2</sup> squared inter-grain pinholes inside GB. The presence of defects in the LSM dense thin films is discarded

## ■ GEOMETRIC EFFECTS

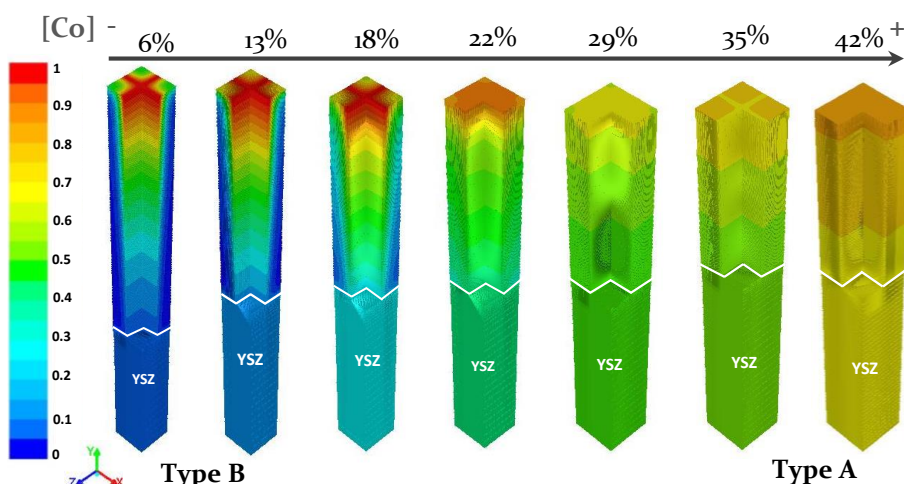
Variation of the grain size and the grain boundary width (according to the grain size study from the structural characterization)

6% [Co] LSMC			
	$D^*_b$ (cm <sup>2</sup> ·s <sup>-1</sup> )	$D^*_{GB}$ (cm <sup>2</sup> ·s <sup>-1</sup> )	$k^*_{GB}$ (cm·s <sup>-1</sup> )
<b>Grain width (nm) and 1 nm GB</b>			
15	$3.5 \times 10^{-17}$	$3.9 \times 10^{-12}$	$2.6 \times 10^{-4}$
21	$7.0 \times 10^{-17}$	$3.5 \times 10^{-12}$	$2.0 \times 10^{-4}$
27	$1.1 \times 10^{-16}$	$3.2 \times 10^{-12}$	$1.3 \times 10^{-4}$
<b>GB width (nm) and 21 nm grain</b>			
0.5	$9.8 \times 10^{-17}$	$4.3 \times 10^{-12}$	$3.0 \times 10^{-4}$
1.5	$5.8 \times 10^{-17}$	$2.1 \times 10^{-12}$	$1.9 \times 10^{-4}$
13% [Co] LSMC			
<b>Grain width (nm) and 1 nm GB</b>			
18	$5.5 \times 10^{-17}$	$2.9 \times 10^{-12}$	$8.2 \times 10^{-5}$
25	$9.8 \times 10^{-17}$	$2.8 \times 10^{-12}$	$8.0 \times 10^{-5}$
32	$1.7 \times 10^{-16}$	$2.6 \times 10^{-12}$	$7.9 \times 10^{-5}$
<b>GB width (nm) and 25 nm grain</b>			
0.5	$1.9 \times 10^{-16}$	$2.7 \times 10^{-12}$	$1.0 \times 10^{-4}$
1.5	$8.0 \times 10^{-17}$	$2.1 \times 10^{-12}$	$7.9 \times 10^{-5}$

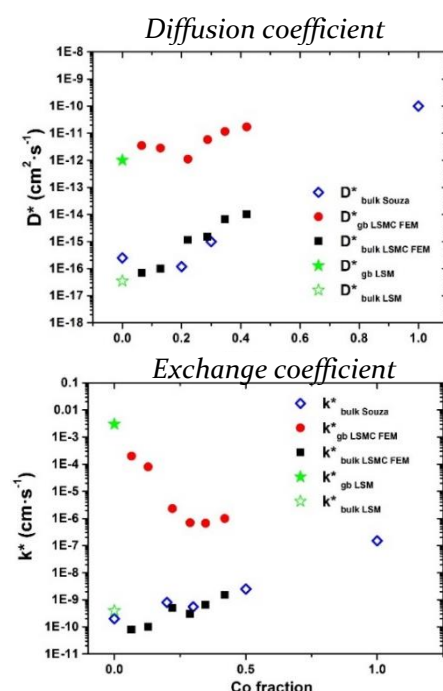
- ✓ The variation of the grain width mainly affects  $D^*_b$  and  $D^*_{GB}$ .
- ✓ The  $k^*_{GB}$  value is much less sensitive.
- ✓ Changes in the  $k^*_b$  value are insignificant.
- ✓ The effect of the grain boundary width modifies in the same order the  $k^*_{GB}$ ,  $D^*_{GB}$  and  $D^*_b$  due to the decisive influence of GBs and their interaction with the bulk.

## ■ DOPANT EFFECT : $\text{La}_{0.8}\text{Sr}_{0.2}\text{Mn}_{1-x}\text{Co}_x\text{O}_{3\pm\delta}$ (LSMC)

Isotopic fraction maps for LSMC/YSZ calculated by FEM



An increase in Co concentration leads to a change of the diffusion regime according to the Harrison's classification from the type B ( $D^*_b$  and  $D^*_{GB}$ ) to the type A (effective diffusion coefficient  $D_{eff}$ ).



- ✓ Large increase in both  $D^*_b$  and  $D^*_{GB}$  for %Co > 20%, probably related to an increase of the  $V_{O^{\cdot\cdot}}$ .
- ✓ The increase of  $V_{O^{\cdot\cdot}}$  is similar in the grain and GBs.
- ✓  $k^*_b$  increases with Co content, probably related to an increase of the  $V_{O^{\cdot\cdot}}$  in the grain.
- ✓  $k^*_{GB}$  decreases with %Co up to 22%. It might be due to a higher  $E_a$  for  $\text{O}_2$  adsorption in LSMC compared to LSM.
- ✓ The  $\text{O}^{2-}$  incorporation probably is enhanced due to high density of GBs in the nanostructure.